

Electrochemical capacitance of a leaky nano-capacitor

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Abstract

We report a detailed theoretical investigation on electrochemical capacitance of a nanoscale capacitor where there is a DC coupling between the two conductors. For this “leaky” quantum capacitor, we have derived general analytic expressions of the linear and second order nonlinear electrochemical capacitance within a first principles quantum theory in the discrete potential approximation. Linear and nonlinear capacitance coefficients are also derived in a self-consistent manner without the latter approximation and the self-consistent analysis is suitable for numerical calculations. At linear order, the full quantum formula improves the semiclassical analysis in the tunneling regime. At nonlinear order which has not been studied before for leaky capacitors, the nonlinear capacitance and nonlinear nonequilibrium charge show interesting behavior. Our theory allows the investigation of crossover of capacitance from a full quantum to classical regimes as the distance between the two conductors is changed.

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I. INTRODUCTION

The most significant development in electronic devices has been the progressive miniaturization of them: it is now common to fabricate electron device structures with dimensions at mesoscopic scale and even at nanoscale. One of the important directions in nanoelectronics research is to understand device properties which relate to the existence of small dimensions. In this work, we investigate the notion of electrochemical capacitance for conductors in the mesoscopic or nanoscale and the nonequilibrium charge distribution at the nonlinear level. Using a full first principles quantum theory, a semiclassical theory, as well as a direct numerical solution, we construct an overall physical picture on the effects of quantum tunneling to the nanoscale capacitance. We also investigate the density of state correction to capacitance at nonlinear orders of the external bias. For a pair of very small conductors, it has been known that the capacitance may be quite different from the usual parallel plate capacitance formula given by $C_o \sim 1/W$, where W is the distance between the two plates. Apart from the usual electrostatic fringe effect, there are quantum corrections to the classical formula. Quantum corrections come from several sources: a finite density of states of the plates, a finite screening length to the electron-electron interactions, and quantum tunneling.

The quantum correction to classical formula due to density of states (DOS) has been theoretically [1,2] and experimentally [3] investigated in the literature by a number of authors. For semiconductor heterojunctions they found that DOS contributes a factor to the capacitance given by $C_{DOS} = e^2(dN/dE)$ where dN/dE is the total density of states of the system. Thus the total capacitance C is a result of a series connection of C_o and C_{DOS} : $1/C = 1/C_o + 1/C_{DOS}$. This formula has been theoretically studied from a dynamic point of view and was derived in the low frequency limit of an AC theory [4,5]. Significantly, these investigations on DOS effects focused on the *linear* capacitance coefficient C , namely C is the linear coefficient of the charge pile-up on a capacitor plate as a function of the external bias voltage. Recently some attention [6] has been paid to the nonlinear regime: due to the nonlinear bias dependence of local DOS there is also a nonlinear bias dependence of the

nonequilibrium charge. The nonlinear capacitance coefficients is one of the topics which will be further investigated below.

Mesoscopic electrochemical capacitance has been found [7] to obey, within a magnetic field, weaker Onsager-Casimir symmetry relations. For example it is no longer a symmetric function of magnetic field [7]. The asymmetry of electrochemical capacitance has been observed for a gate close to the edge of a quantum Hall bar [8]. The magneto-electrochemical capacitance of a three-dimensional quantum dot with three-probes has been studied numerically in detail in Ref. [9]. It is found that at low magnetic fields the magnetocapacitance shows a large asymmetry under a magnetic field reversal. At higher fields the capacitance is dominated by Aharonov-Bohm type oscillations and the fluctuations of the asymmetry is somewhat reduced. For the III-V tunneling heterostructures, the contribution of the density of states on the magnetocapacitance is also studied [10]. The investigation of the frequency dependent electrochemical capacitance for a parallel plate capacitor within the nonequilibrium Green's function formalism show interesting oscillatory behavior which is related to the retardation effect of the Maxwell equations [11].

As mentioned above, quantum tunneling effect changes the capacitance value as predicted by the classical formula. This effect was recently addressed using numerical analysis of atomic junctions [12]. Numerical calculations [12] of aluminum atomic junctions with tiny DOS showed that at small distances W , the electrochemical capacitance $C = C(W)$ actually *increases* with W which is due to tunneling effect. One expects that at larger W when tunneling effects is diminished, the capacitance would follow a crossover to the classical prediction. However due to the very small DOS of the atomic junction [12], no crossover to the classical formula was found in these atomic systems.

The correction to classical capacitance formula due to a finite screening length was most clearly demonstrated from a dynamic point of view on the electrochemical capacitance, due to the work of Christen and Büttiker [13] where a conducting quantum point contact (QPC) was found to establish a nonequilibrium charge resulting to a finite electrochemical capacitance. In particular they have derived a formula for a QPC with a semiclassical

method [13],

$$\frac{R}{C} = \frac{1}{C_o} + \frac{1}{e^2 \frac{dN_1}{dE}} + \frac{1}{e^2 \frac{dN_2}{dE}} \quad , \quad (1)$$

where R is essentially a reflection probability of the QPC, C_o is geometric capacitance, dN_1/dE and dN_2/dE are the total DOS in the regions to the left and to the right of the QPC. Qualitatively, the numerical data of the aluminum tunnel junction [12] were consistent with Eq. (1) in that C is proportional to R . Formula (1) is termed “semiclassical” because not all the relevant scattering local partial density of states (LPDOS) were included in its derivation. The notion of scattering LPDOS was proposed by Büttiker [4] and subsequently by Gasparian, Christen and Büttiker [14], and it plays a very important role in low frequency AC transport as well as nonlinear DC transport. LPDOS describes the probability of various scattering processes [14]. Consider a tunnel barrier as shown in Fig. (1). An example of a LPDOS is denoted by $d\sigma_{22}(\mathbf{r})/dE$ which is the contribution of carriers at position $\mathbf{r}$ to the DOS, and these carriers come from region 2 and ultimately return to region 2. Although region 2 is on the right hand side of the tunnel barrier (see Fig. (1)), $d\sigma_{22}(\mathbf{r})/dE \neq 0$ even when $\mathbf{r}$ is on the left hand side of the barrier due to tunneling. In deriving [13] Eq. (1) for a QPC, contributions such as $d\sigma_{22}(\mathbf{r})/dE$ with position $\mathbf{r}$ on the other side of the QPC, has been neglected.

In this paper, we will further investigate nanoscale capacitors where the two conductors have a DC coupling, namely there is a DC “leakage” from one conductor to the other. For the linear electrochemical capacitance of a tunnel barrier, we improve formula (1) by including the tunneling contributions of various LPDOS. This way a full quantum capacitance formula is derived and will be compared with (1). For a single tunnel barrier there is a quantitative difference between these results in the quantum regime, and the difference diminishes as the classical limit is approached. The quantum formula and Eq. (1) allow investigations of a crossover from tunneling dominated regime to the classical regime, by varying the barrier width W . Our derivation as well as the derivation of Eq. (1) are within the discrete potential model [15] that used an approximation where the space is coarse grained into a few regions.

For the tunnel barrier they are regions to the left of the barrier (denoted by Ω_1), to the right of the barrier (Ω_2), and the barrier region. To confirm that this approximation does not affect the predictions qualitatively, we have carried out extensive numerical calculations of the LPDOS by directly solving them without the approximation.

Recently, the theory of non-linear electrochemical capacitance has been formulated using the response theory [16]. The electrochemical capacitance of a parallel plate capacitor is a nonlinear function of the bias voltage due to the finite DOS near the plates as mentioned above. In this work we will study effect of screening on the nonlinear electrochemical capacitance for the “leaky” capacitor, which is an important problem not investigated before and is relevant for experiments of scanning capacitance microscopy [17] applied to nanosystems. We will derive a general expression of the second and third order nonlinear quantum electrochemical capacitance using the discrete potential model [15]. Our analysis naturally deduces, in appropriate approximations, a semiclassical expression of the *second order* nonlinear electrochemical capacitance for QPC. Finally, to compare with results of the discrete potential model and semiclassical result, we have directly solved the Poisson equation and calculated numerically the linear and the second order nonlinear electrochemical capacitance as a function of barrier width of a single tunneling barrier.

The main results of our investigation are summarized in the following sections. In the next section we present our theory of the nonlinear electrochemical capacitance where full quantum tunneling effect is taken into account. At the linear order, we compare the quantum formula with the semiclassical formula; and using scattering Green’s functions we derive second and third order nonlinear results. In Sections III we present numerical calculations which is compared with the theoretical analysis. Finally the last section summarizes the main findings.

II. THEORY

In general a two-probe system can be considered as having three regions, a scattering region and two electrodes. This is illustrated in Fig. (1) where the scattering region includes the scattering potential barrier, and two electrodes are the regions to the left (Ω_1) and to the right (Ω_2) of the barrier. We are interested in the electrochemical capacitance of this system by including the full quantum effects. If we refer regions Ω_1 and Ω_2 as the two conductors of a capacitor, we are dealing with a “leaky” capacitor since the potential barrier provides a DC coupling between the conductors. Far away from the the regions, the system is connected to contacts which are viewed as large thermodynamic reservoirs, hence in the contacts the electron distributions are Fermi-Dirac. When a voltage V_1 is applied at contact 1 and V_2 at contact 2, assume $V_1 < 0$, the electron energy band at contact 1 is changed by $d\mu_1 = eV_1$ and at contact 2 by $d\mu_2 = eV_2$. The relative electrochemical potential difference is thus $d\mu = d\mu_1 - d\mu_2$: due to $d\mu$ electrons are injected into the system. The force acting on electrons comes from a combination of external and internal fields. In principle, motion of electrons in the total field can be solved by Schrödinger equation. In particular we will adopt the scattering matrix approach formulated by Landauer [18], Imry [19], and Büttiker [20,21] to solve the single electron transport problem which gives the necessary LPDOS needed for the calculation of electrochemical capacitance.

Study of electrochemical capacitance is closely related to the calculation of changes of the local band $eU(\mathbf{r})$. It is clear that this local band change near the tunnel barrier is different from the shift $d\mu_k$ which occurs at the contacts far away from the barrier. At equilibrium conditions the electron energy near the barrier is given by $E_t = E + d\mu_k - eU(\mathbf{r})$ where E is the electron energy at Fermi level without the applied voltage. $d\mu_k$ denotes the electrochemical potential change in reservoir k . Near the barrier electrons accumulate for regions where $E_t > E$ and deplete for regions where $E_t < E$. It is these accumulated charges which we must evaluate. The internal potential build-up $eU(\mathbf{r})$ can be solved by a self-consistent Poisson equation. For simplicity of discussion, in the following we use $U_1(\mathbf{r})$

and $U_2(\mathbf{r})$ to denote this potential in regions Ω_1 and Ω_2 respectively. Furthermore, analytical derivation of capacitance formula in terms of microscopic quantities is possible if we use a space-averaged potential U_k to replace the space dependent potential $U_k(\mathbf{r})$, as was done in Ref. [13]. This corresponds to the discrete potential model proposed by Christen and Buttiker [15].

We represent the number of electrons in the region Ω_k ($k = 1, 2$) incident from contact α ($\alpha = 1, 2$) by $\sigma_{k\alpha}$, which is a function of electron energy E_t . Hence $\sigma_{k\alpha} = \sigma_{k\alpha}(E + d\mu_\alpha - eU_k)$. The number of electrons without external bias (at equilibrium) is thus $\sigma_{k\alpha}(E)$, because $U_k \rightarrow 0$ when $d\mu \rightarrow 0$. By definition, the electrostatic (geometrical) capacitance C_o between the two regions Ω_1 and Ω_2 is given by $C_o = \Delta Q_1/(U_1 - U_2)$ (or by $C_o = \Delta Q_2/(U_2 - U_1)$) where ΔQ_k ($k = 1, 2$) is the charge measured from the equilibrium value in region Ω_k regardless where they have come from, *i.e.* $\Delta Q_k = \sum_\alpha [\sigma_{k\alpha}(E_t) - \sigma_{k\alpha}(E)]$, where, to avoid confusion we use $k = I, II$ to denote the regions from now on. Since there are two electrodes, *i.e.* $\alpha = 1, 2$, ΔQ_k thus consists of two parts. For example, in region Ω_I (*i.e.* $k = I$), a part of ΔQ_I is due to electrons incident from electrode $\alpha = 1$ which are scattered back to region $k = I$. We denote this part of ΔQ_I by $\Delta N_1(\Omega_I) = \sigma_{I1}(E + d\mu_1 - eU_1) - \sigma_{I1}(E)$. The second part of ΔQ_I comes from electrons launched at electrode $\alpha = 2$ but ended up in region $k = I$, this part is expressed by $\Delta N_2(\Omega_I) = \sigma_{I2}(E + d\mu_2 - eU_1) - \sigma_{I2}(E)$. Hence $\Delta Q_I = \Delta N_1(\Omega_I) + \Delta N_2(\Omega_I)$.

The above partition of local charge according to where it comes from can be equally applied to the scattering local partial density of states [14]. Hence, for example, $d\sigma_{12}(\Omega_I)/dE$ is the LPDOS which is the DOS for an electron incident from electrode 2 passing through region Ω_I and reaching electrode 1. Similarly, $d\sigma_{22}(\Omega_I)/dE$ is the LPDOS which is the DOS for an electron incident from electrode 2 passing through region Ω_I and eventually returning to electrode 2 [22]. Both of these LPDOS describe the tunneling process. This latter term is neglected for a semiclassical calculations and is nonzero for a quantum analysis, as emphasized in Ref. [14]. They both contribute to the electrochemical capacitance [23] which is the experimentally measured capacitance defined by

$$C_\mu = \frac{eQ_1}{d\mu_1 - d\mu_2} . \quad (2)$$

The rest of the paper is devoted to calculate C_μ including all the quantum effects discussed above.

Based on the above discussions, we can write down the following two equations [6] for the classical geometrical capacitance. Using charges of region Ω_I ,

$$\begin{aligned} C_o \times (U_1 - U_2) &= \sigma_{I1}(E + d\mu_1 - U_1) - \sigma_{I1}(E) \\ &+ \sigma_{I2}(E + d\mu_2 - U_1) - \sigma_{I2}(E) . \end{aligned} \quad (3)$$

Using charges of region Ω_{II} ,

$$\begin{aligned} C_o \times (U_2 - U_1) &= \sigma_{II1}(E + d\mu_1 - U_2) - \sigma_{II1}(E) \\ &+ \sigma_{II2}(E + d\mu_2 - U_2) - \sigma_{II2}(E) . \end{aligned} \quad (4)$$

Because the same charge defines electrochemical capacitance C_μ as given by Eq. (2), we have

$$C_o \times (U_1 - U_2) = C_\mu \times (d\mu_1 - d\mu_2) . \quad (5)$$

Finally, it is important to remember that the internal electrostatic potential U_k is a function of the electrochemical potential at the reservoirs,

$$U_1 = U_1(\mu_1, \mu_2) , \quad U_2 = U_2(\mu_1, \mu_2) . \quad (6)$$

In above equations we have set electron charge $e = 1$ so that $d\mu_\alpha = V_\alpha$ which is the bias voltage at reservoir α .

Equations (3, 4, 5) are the fundamental equations which we will use to derive quantum corrections to C_o at the linear and nonlinear orders. Because our theory is gauge invariant, without loss of generality we set $V_1 = V$ and $V_2 = 0$ throughout the following analysis.

A. Linear electrochemical capacitance formula

As discussed above, a semiclassical formula of the linear electrochemical capacitance has been derived in Ref. [13] in the form of Eq. (1). In this subsection we derive a full quantum formula.

Taking derivatives of Eqs. (3,4, 5) with respect to V , we obtain

$$C_o(\frac{dU_1}{dV} - \frac{dU_2}{dV}) = \frac{d\sigma_{I1}}{dE_1}(1 - \frac{dU_1}{dV}) - \frac{d\sigma_{I2}}{dE_2} \frac{dU_1}{dV} \quad (7)$$

$$C_o(\frac{dU_2}{dV} - \frac{dU_1}{dV}) = \frac{d\sigma_{II1}}{dE_3}(1 - \frac{dU_2}{dV}) - \frac{d\sigma_{II2}}{dE_4} \frac{dU_2}{dV} \quad (8)$$

$$C_o(\frac{dU_1}{dV} - \frac{dU_2}{dV}) = C_\mu \quad (9)$$

where $E_1 \equiv E + V_1 - U_1$, $E_2 \equiv E + V_2 - U_1$, $E_3 = E + V_1 - U_2$, and $E_4 = E + V_2 - U_2$. In deriving the last equation, we have assumed that C_μ has no bias voltage dependence [24]. In general the above derivatives should be done at a finite bias voltage V , but experimentally one can control this parameter and use very small voltages [3] $V \ll E$. Hence we will evaluate the derivatives at the $V \rightarrow 0$ limit. In the above equations, the quantity $d\sigma_{k\alpha}/dE_i$ is just the LPDOS in the corresponding regions as discussed above (where we used the notation such as $d\sigma_{I1}/dE$).

From Eqs. (7, 8, 9), eliminating dU_1/dV and dU_2/dV , we obtain

$$\begin{aligned} \frac{\frac{d\sigma_{I1}}{dE_1}}{\frac{d\sigma_{I1}}{dE_1} + \frac{d\sigma_{I2}}{dE_2}} - \frac{\frac{d\sigma_{II1}}{dE_3}}{\frac{d\sigma_{II1}}{dE_3} + \frac{d\sigma_{II2}}{dE_4}} &= \frac{1}{C_o} + \frac{1}{\frac{d\sigma_{II1}}{dE_1} + \frac{d\sigma_{I2}}{dE_2}} \\ &+ \frac{1}{\frac{d\sigma_{II1}}{dE_3} + \frac{d\sigma_{II2}}{dE_4}}. \end{aligned} \quad (10)$$

The electrochemical capacitance C_μ calculated from this formula is fully quantum: all the tunneling effects are taken into account through the appropriate LPDOS which can be evaluated from quantum scattering calculations (see below).

The general result (10) can be reduced to the semiclassical form Eq. (1) if we apply the semiclassical version of the LPDOS. In the semiclassical limit, Ref. [13] showed that the LPDOS is given by

$$\frac{d\sigma_{k\alpha}}{dE} = \sum_{\beta} D_k \left[\frac{T}{2} + \delta_{\beta\alpha} (R\delta_{\beta k} - \frac{T}{2}) \right] \quad (11)$$

where T is the transmission coefficient, R is related to the reflection coefficient, $D_I \equiv d\sigma_{I1}/dE_1 + d\sigma_{I2}/dE_2$ and $D_{II} \equiv d\sigma_{II1}/dE_1 + d\sigma_{II2}/dE_2$ are essentially total local DOS in regions Ω_I and Ω_{II} . Substituting (11) into Eq. (10), it is straightforward to prove that Eq.(10) reduces to the result of Ref. [13]:

$$\frac{R}{C_{11}} = \frac{1}{C_o} + \frac{1}{D_I} + \frac{1}{D_{II}} \quad , \quad (12)$$

where we used notation C_{11} to denote the *linear* electrochemical capacitance C_{μ} . If we further set $R = 1$, *i.e.* no DC coupling is allowed between the two regions, formula (12) reduces to the familiar electrochemical capacitance of two plates where there is no DC current flowing through [5].

In Section III we will provide numerical plots of the full quantum and semiclassical formula, and compare them with direct numerical solution of the same problem which does not employ the discrete potential model.

B. Nonlinear electrochemical capacitance formula

We now derive the second order nonlinear electrochemical capacitance from the fundamental equations (3), (4), and (5). A similar procedure leads to higher order results. To obtain nonlinear results we expand Eqs.(3) and (4) order by order in terms of the bias voltage V_{β} and internal potential U_{β} . The expansion coefficients are energy derivatives of the spectral function $\sigma_{k\alpha}$, where the first derivative is the linear LPDOS used in the last section, while the second derivative is the second order nonlinear LPDOS which is analyzed in the Appendix A. Similarly higher order derivatives are the corresponding higher order nonlinear LPDOS. To simplify notation in the following we denote $D_{k\alpha} \equiv d\sigma_{k\alpha}/dE$ and $\bar{D}_{k\alpha} \equiv d^2\sigma_{k\alpha}/dE^2$.

To second order in bias voltage, Eqs.(3) and (4) become

$$\begin{aligned}
C_0(U_1 - U_2) &= \sum_{\beta} D_{I\beta} V_{\beta} - D_I U_1 \\
&+ \sum_{\beta} \frac{1}{2} \bar{D}_{I\beta} (V_{\beta} - U_1)^2
\end{aligned} \tag{13}$$

$$\begin{aligned}
-C_0(U_1 - U_2) &= \sum_{\beta} D_{II\beta} V_{\beta} - D_{II} U_2 \\
&+ \frac{1}{2} \sum_{\beta} \bar{D}_{II\beta} (V_{\beta} - U_2)^2 .
\end{aligned} \tag{14}$$

Using Eq.(11) and expression (45) of Appendix A, in the semiclassical limit the above two equations become

$$\begin{aligned}
C_0(U_1 - U_2) &= D_I \left(\frac{T}{2} + R \right) V_1 + D_I \frac{T}{2} V_2 - D_I U_1 \\
&+ \frac{1}{2} R \bar{D}_I (V_1 - U_1)^2 + \frac{1}{2} T \bar{D}_I (V_2 - U_1)^2
\end{aligned} \tag{15}$$

and

$$\begin{aligned}
-C_0(U_1 - U_2) &= D_{II} \frac{T}{2} V_1 + D_{II} \left(\frac{T}{2} + R \right) V_2 - D_{II} U_2 \\
&+ \frac{1}{2} T \bar{D}_{II} (V_1 - U_2)^2 + \frac{1}{2} R \bar{D}_{II} (V_2 - U_2)^2 .
\end{aligned} \tag{16}$$

In terms of C_{11} of Eq. (12), we obtain internal potential U_1 and U_2 to first order in voltage,

$$U_1 = R V_1 + \frac{T}{2} (V_1 + V_2) - \frac{C_{11}}{D_I} (V_1 - V_2) \tag{17}$$

and

$$U_2 = R V_2 + \frac{T}{2} (V_1 + V_2) + \frac{C_{11}}{D_{II}} (V_1 - V_2) . \tag{18}$$

Substituting Eqs.(17) and (18) into the quadratic terms of Eqs.(15) and (16), we obtain

$$\begin{aligned}
C_0(U_1 - U_2) &= D_I \left(\frac{T}{2} + R \right) V_1 + D_I \frac{T}{2} V_2 - D_I U_1 \\
&+ \frac{1}{2} R \bar{D}_I \left(\frac{T}{2} + \frac{C_{11}}{D_I} \right)^2 (V_1 - V_2)^2 \\
&+ \frac{1}{2} T \bar{D}_I \left(R + \frac{T}{2} - \frac{C_{11}}{D_I} \right)^2 (V_1 - V_2)^2
\end{aligned} \tag{19}$$

and

$$\begin{aligned}
-C_0(U_1 - U_2) &= D_{II} \frac{T}{2} V_1 + D_{II} \left(\frac{T}{2} + R \right) V_2 - D_{II} U_2 \\
&+ \frac{1}{2} T \bar{D}_{II} \left(R + \frac{T}{2} - \frac{C_{11}}{D_{II}} \right)^2 (V_1 - V_2)^2 \\
&+ \frac{1}{2} R \bar{D}_{II} \left(\frac{T}{2} + \frac{C_{11}}{D_{II}} \right)^2 (V_1 - V_2)^2 .
\end{aligned} \tag{20}$$

Combining the above two equations, we finally arrive at

$$C_0(U_1 - U_2) = C_{11}(V_1 - V_2) + \frac{1}{2} C_{111}(V_1 - V_2)^2 \tag{21}$$

with the nonlinear capacitance

$$\begin{aligned}
C_{111} &= C_{11} \left[\frac{\bar{D}_I}{D_I} \left(\frac{T}{2} + \frac{C_{11}}{D_I} \right)^2 - \frac{\bar{D}_{II}}{D_{II}} \left(\frac{T}{2} + \frac{C_{11}}{D_{II}} \right)^2 \right] \\
&+ \frac{T}{R} C_{11} \left[\frac{\bar{D}_I}{D_I} \left(R + \frac{T}{2} - \frac{C_{11}}{D_I} \right)^2 \right. \\
&\quad \left. - \frac{\bar{D}_{II}}{D_{II}} \left(R + \frac{T}{2} - \frac{C_{11}}{D_{II}} \right)^2 \right]
\end{aligned} \tag{22}$$

This result indicates that the second order nonlinear electrochemical capacitance can be expressed in terms of microscopic quantities such as the various LPDOS as well as transmission and reflection coefficients. All of these are calculable and have been studied before. Hence this result is very useful in practical predictions of nonlinear capacitance coefficient, and it is valid even if there is a DC coupling between the two polarization regions of the conductor.

The general expression (22) is reduced in certain limiting situations. First, for a spatially symmetric system where $D_I = D_{II}$ and $\bar{D}_I = \bar{D}_{II}$, Eq. (22) gives $C_{111} = 0$. This is expected due to symmetry: since C_{111} is the coefficient of the charge distribution expanded in second order of bias voltage (*e.g.* Eq. (21)), it must vanish as charge $Q \rightarrow -Q$ for symmetrical systems when $V \rightarrow -V$. Second, for a capacitor without DC coupling between the two conductors, *i.e.* for cases $T = 0$ identically, Eq.(22) becomes

$$C_{111} = C_{11}^3 \left(\frac{\bar{D}_I}{D_I^3} - \frac{\bar{D}_{II}}{D_{II}^3} \right) \tag{23}$$

which was first derived in a response theory [16]. Finally, a point worthy some discussion is the “resonant transmission point” by setting $T = 1$ and $R = 0$. For this case from Eq. (12) the linear electrochemical capacitance $C_{11} = 0$. But from Eq. (22) $C_{111} \neq 0$ and is given by

$$C_{111} = \frac{1}{4} \left(\frac{\bar{D}_I}{D_I} - \frac{\bar{D}_{II}}{D_{II}} \right) \frac{1}{C_0^{-1} + D_I^{-1} + D_{II}^{-1}} , \quad (24)$$

which is generally nonzero. Apparently we would expect no charge accumulation when $T = 1$ hence C_{111} and all other capacitance coefficients would vanish. However the $T = 1$ limit in the above formula only states the fact that *injected* charges are going through from one capacitor plate to the other at the *linear* order, and it does not implicate the behavior of the charges at nonlinear order where in general $T = T(E, U)$. Thus in setting $T(E) = 1$ in Eq. (22) is not the true resonant transmission point: at nonlinear order the resonance occurs at $T(E, U) = 1$.

C. Analysis beyond discrete potential model

So far we have derived the linear and nonlinear electrochemical capacitance coefficients within the discrete potential model, in which the internal potential U_k is parametrized in terms of a geometrical capacitance C_o . This parametrization is necessary in order to carried out analytical derivations, and it is adequate to reveal qualitative features of the physics. On the other hand, if one is willing to perform numerical calculations, it is possible to go beyond the discrete potential approximation. In this case we can solve the internal potential $U = U(\mathbf{r})$ from a self-consistent Poisson equation. In this subsection we derive capacitance expressions which are suitable beyond the discrete potential model.

We start from the charge pile-up written as a three-dimensional spatial integral of the charge density [16]

$$\begin{aligned} Q_\alpha &= \int_{\Omega_\alpha} \rho(x) d^3x \\ &\equiv \sum_\beta C_{\alpha\beta} V_\beta + \frac{1}{2} \sum_{\beta\gamma} C_{\alpha\beta\gamma} V_\beta V_\gamma + \dots \quad . \end{aligned} \quad (25)$$

Ref. [6] has shown that charge density $\rho(x)$ is given in terms of the linear and nonlinear LPDOS, as

$$\begin{aligned}\rho(x) &= \sum_{\alpha} \frac{d\sigma_{\alpha}(x)}{dE} (V_{\alpha} - U(x)) \\ &+ \frac{1}{2} \sum_{\alpha} \frac{d^2\sigma_{\alpha}(x)}{dE^2} (V_{\alpha} - U(x))^2 + \dots \quad .\end{aligned}\quad (26)$$

To proceed further we must solve the internal Coulomb potential $U(x)$ by the Poisson equation

$$-\nabla^2 U(x) = 4\pi\rho(x) \quad . \quad (27)$$

As done previously [5,16], for perturbative analysis of the electrochemical capacitance we introduce the characteristic potential $u(x)$

$$U(x) = \sum_{\alpha} u_{\alpha}(x) V_{\alpha} + \frac{1}{2} \sum_{\alpha\beta} u_{\alpha\beta} V_{\alpha} V_{\beta} + \dots \quad . \quad (28)$$

Hence instead of solving $U(x)$ we solve for $u(x)$ order by order. From Eqs.(26) to (28), we find Poisson like equations for the characteristic potentials [26]

$$-\nabla^2 u_{\alpha} + 4\pi \frac{d\sigma}{dE} u_{\alpha} = 4\pi \frac{d\sigma_{\alpha}}{dE} \quad (29)$$

and

$$-\nabla^2 u_{\alpha\beta} + 4\pi \frac{d\sigma}{dE} u_{\alpha\beta} = 4\pi \frac{d\tilde{\sigma}_{\alpha\beta}}{dE} \quad (30)$$

where [16]

$$\frac{d\tilde{\sigma}_{\alpha\beta}}{dE} = \frac{d^2\sigma_{\alpha}}{dE^2} \delta_{\alpha\beta} - \frac{d^2\sigma_{\alpha}}{dE^2} u_{\beta} - \frac{d^2\sigma_{\beta}}{dE^2} u_{\alpha} + \frac{d^2\sigma}{dE^2} u_{\alpha} u_{\beta} \quad (31)$$

With the help of Eqs.(29) and (30), the electrochemical capacitance can be calculated from the following expressions,

$$C_{\alpha\beta} \equiv \int_{\Omega_{\alpha}} Q_{\beta}(x) d^3x = \int_{\Omega_{\alpha}} \left(\frac{d\sigma_{\beta}}{dE} - \frac{d\sigma}{dE} u_{\beta} \right) d^3x \quad (32)$$

$$C_{\alpha\beta\gamma} \equiv \int_{\Omega_{\alpha}} Q_{\beta\gamma}(x) d^3x = \int_{\Omega_{\alpha}} \left(\frac{d\tilde{\sigma}_{\beta\gamma}}{dE} - \frac{d\sigma}{dE} u_{\beta\gamma} \right) d^3x \quad (33)$$

where $Q_\beta(x)$ and $Q_{\beta\gamma}(x)$ are linear and nonlinear nonequilibrium charge distributions. These results are useful for numerical calculations where all the quantities on the right hand side can be obtained accurately. For instance Eq. (32) has been used in the analysis of atomic junctions [12]. Eq. (33) is derived for the first time here.

To end this section we note that in a numerical calculation, the LPDOS $d\sigma_\alpha/dE$ can be calculated using the scattering wavefunction [27]

$$\frac{d\sigma_\alpha(x)}{dE} = \frac{1}{\hbar v} |\psi(x)|^2 \quad (34)$$

where v is the velocity of the carrier and $\psi(x)$ is the scattering wavefunction for incident wave coming from lead α . Eqns. (29, 30) can be numerically solved on a three-dimensional grid, for instance a multi-grid technique was employed in Ref. ([12]) for such a purpose.

III. NUMERICAL RESULTS

In this section we present numerical plots for electrochemical capacitance of the tunnel barrier in Fig. (1). The numerical curves were obtained along two lines: by plotting the analytical expressions (10, 12, 22) which are within the discrete potential model; and by direct numerical solution of the self-consistent internal potential $U(\mathbf{r})$ and then applying expressions (32) and (33).

To be specific, we choose a numerical calculation box with size $x_L - x_R = 12\lambda_F$ where λ_F is Fermi wavelength of the scattering electron. Here $x_{L,R}$ are the positions of left and right boundary of the calculation box. We fix the tunnel barrier of width W symmetrically in the center of the calculation box. This way the regions Ω_I and Ω_{II} discussed above are given by the space between the calculation box and the barrier walls. The quantum scattering problem by this single barrier is easily solved, from which we obtain various LPDOS using the scattering wavefunction according to Eq.(34). To apply expressions (10, 12, 22) which are appropriate for the discrete potential model, we spatially average these LPDOS in the respective regions which gives us the corresponding quantities in these expressions. On the

other hand, in applying expressions (32, 33) which uses the full spatial dependent internal potential, the spatial integration range should be the Thomas-Fermi screening length [5] as discussed in Appendix B. The screening length is determined [5] by solving the Poisson-like equations (29) (and (30) in the nonlinear case). From now on we will use atomic units such that $\hbar = 2m = e = 1$. In typical nanoscale systems [29] with charge density 10^{15} , Fermi wavelength $\lambda_F \sim 47nm$. In the following we use λ_F to set the unit for length and choose Fermi energy $E_F = 0.31$.

Fig.(2) plots the linear electrochemical capacitance obtained from different approaches as a function of the barrier width W for the fixed barrier height $H_0 = 0.8$: (a). the electrochemical capacitance C calculated numerically from Eq.(32) (solid line); (b). the analytic quantum electrochemical capacitance formula in the discrete potential approximation C_q from Eq.(10) (dotted line); (c). the semiclassical electrochemical capacitance [13] C_s of Eq. (12) (dashed line); (d). the effective classical geometric capacitance $C_o \sim 1/W$ (dot-dashed line). For very large the barrier width, it is clearly shown that all curves approach to the classical behavior $\sim 1/W$ since quantum tunneling effect is negligible. For thin barriers where tunneling effect is significant, the behavior of electrochemical capacitances C , C_q , and C_s are completely different from the classical regime. In this quantum regime as one increases the barrier width, the electrochemical capacitance increases rather than decreases. This increasing behavior at very small W is expected since tunneling tends to diminish charge polarization, thus $C \sim 0$ when $W \sim 0$. Hence $C(W)$ should indeed start from small values and increase a bit before it goes down when W is large enough.

To examine the DOS correction which is another quantum effect, we note that one can only separate out the geometrical effect from the DOS effect in the semiclassical limit (as in Eq. (12)), and in general these effects are mixed. Furthermore, in a discrete potential model all the quantities (both in quantum and semiclassical calculations) are *spatially averaged*, hence capacitances are under-estimated. This is why both C_q and C_s curves are consistently below the full numerical solution C . Fig.(2) shows some difference between the quantum result C_q and semiclassical result C_s . To understand this difference we have plotted the partial

DOS $dn_{11}(\Omega_{II})/dE$ (solid line) and $dn_{12}(\Omega_{II})/dE$ (dotted line) in the inset of Fig.(2). As expected, $dn_{11}(\Omega_{II})/dE$ goes to zero for large barrier widths where the semiclassical theory is a good approximation. It is nonzero in the quantum tunneling regime for small barrier width. $dn_{11}(\Omega_{II})/dE$ is also numerically much less than $dn_{12}(\Omega_{II})/dE$. Hence neglecting $dn_{11}(\Omega_{II})/dE$ in the semiclassical analysis gives a small difference between C_s and C_q in the tunneling regime (see Fig. (2)). To further compare with the semiclassical result of QPC of Ref. [13], we have also examined the behavior of capacitance by varying the barrier height H_0 for a fixed barrier width W : the results using Eqs. (32,10,12) are, again, similar in the quantum regime and the same in the classical regime. When the barrier height H_0 is relatively small, the appearance of quantum mechanism leads to a correction for semiclassical electrochemical capacitance.

The physical behavior of second order nonlinear electrochemical capacitance coefficient C_{111} can be studied for an asymmetric barrier: as discussed above $C_{111} = 0$ for symmetric systems (see Eq.(22)). For the asymmetric barrier where the barrier heights are $H_1 = 0.2$ and $H_2 = 1.0$, shown in the inset of Fig.(3a), Fig. (3a) plots C_{11} versus W and Fig.(3b) plots C_{111} . The linear coefficient C_{11} is very similar to that of Fig.(2) of a symmetric barrier. For the full quantum numerical result (solid line), C_{111} starts from zero and becomes *negative* for very thin barrier, reaches minimum at around $W = 1.0$, and then oscillates around zero. The oscillatory behavior can be traced to oscillations in second order DOS $\bar{D} = d^2N/dE^2$ of Eq.(22). In the inset of Fig.(3b), we plot PDOS D_I and $\bar{D}_I$. Correlating the behavior of C_{111} and PDOS, it is clear that the negative values of C_{111} is due to $\bar{D}$.

In Fig.(4), the linear and nonlinear nonequilibrium charge distribution for this asymmetric barrier, $Q_1(x)$ and $Q_{11}(x)$, are plotted. These quantities, especially $Q_{11}(x)$, have not been studied carefully before. It is thus interesting to offer several observations. (a) The linear charge distribution $Q_1(x)$ is in the form of a resistance dipole [25], whereas the nonlinear charge $Q_{11}(x)$ is more like a quadrupole. (b). The linear charge distribution is numerically much larger than the nonlinear charge distribution. The total charges are conserved, *i.e.*, $\int Q_1(x)dx = \int Q_{11}(x)dx = 0$. (c). In the discrete potential model, the average nonlinear

charge Q_{11} is numerically even smaller. Because of this spatial average, the nonlinear charge distribution becomes a dipole in the discrete potential model. This is responsible for the difference between full quantum calculation and that of the discrete potential model.

IV. DISCUSSION AND SUMMARY

In this work we have investigated the quantum version of a “leaky capacitor” in the coherent nanoscale regime in both linear and nonlinear order in terms of the external bias voltage. We have derived an analytic formula of electrochemical capacitance where the two plates have a DC coupling, and tunneling effects between the two plates are fully included by explicitly using partial local density of states $dn_{\alpha\alpha}(\Omega_k)/dE$. Within the discrete potential model where all quantities are averaged over the polarization regions, analytic expressions for the linear and second order nonlinear electrochemical capacitance have been derived. In addition, linear and nonlinear capacitance coefficients formula are derived in terms of the self-consistent potential, and these formula are suitable for numerical calculations in the full quantum regime. Our calculation showed that the analytic results using the discrete potential model are consistent with the full numerical solution, for the single tunnel barrier structure. The electrochemical capacitance formula derived in this paper are suitable for analyzing AC transport at relatively low frequency. At very high frequency, one has to consider radiation effect thus the quantum equation must be solved self-consistently with the full Maxwell equation instead of the Poisson equation used here.

Quantum behavior of the electrochemical capacitance is found in the tunneling regime that the capacitance increases with the barrier width W . This is in clear contrast to the classical behavior of $1/W$. What is the condition that this non-classical phenomenon be observed ? Let’s consider this question using the semiclassical formula [13] Eq. (12) which can be rewritten as

$$C \approx \frac{R}{\frac{1}{C_o} + \frac{1}{D}} . \quad (35)$$

For tunneling, $R \approx [1 - \exp(-W/l)]$ where l is a characteristic length depending on system details such as the barrier heights. When $C = C(W)$ increases with W , we have $\partial C/\partial W > 0$ which gives to a condition for the range of W that allows the nonclassical behavior. Using Eq. (35), for tiny capacitor plates $D \ll C_o$, one can have a reasonable and experimentally accessible range of order l . On other hand for large plates $D \gg C_o$, one can not observe the nonclassical effect unless W is several orders smaller than l which is not experimentally accessible. Hence the condition to observe the non-classical behavior is tunneling and also small DOS. Systems which satisfy these conditions are nanoscale capacitors, whereas capacitors with large plates such as Josephson junctions (macroscopic) do not satisfy the DOS condition.

The nonlinear theory developed here can be pushed to higher order analytically within the discrete potential model. At linear order the full quantum formula (10) and the semiclassical formula (12) give certain numerical difference in the quantum regime. There is a more substantial numerical difference between the discrete potential model and the full self-consistent numerical calculation using expressions (32) and (33), although all these results are qualitatively consistent. At second nonlinear order, the nonequilibrium charge distribution behaves as a quadrupole, this is compared to the resistance dipole when linear order charge is considered. It is interesting to note that the nonlinear charge can be nonzero when linear charge is zero: this happens at the linear resonance point. The nonlinear capacitance coefficient also behaves quite differently from the its linear counterpart, as shown by its oscillatory behavior linked to the nonlinear LPDOS.

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V. APPENDIX A.

The nonlinear electrochemical capacitance depends on the nonlinear LPDOS, as shown in Section II. In this Appendix, we derive the nonlinear (2nd order) LPDOS using Green's functions. In particular we have to relate the second order LPDOS $d^2\sigma_{\alpha\beta}/dE^2$ to the total LDOS $d^2\sigma/dE^2$, where indices α, β label the leads.

We start from the definition of LPDOS expressed in terms of the Green's function [30],

$$\frac{d\sigma_{12}(x)}{dE} = Re[2\pi i(G^r\Gamma_2 G^a\Gamma_1 G^r)_{xx}] \quad (36)$$

where G^r is the retarded Green's function, Γ_α is the linewidth function, and $Re[...]$ denotes the real part of [...]. Using relation [14]

$$G^r_{xx_1} G^r_{x_2x} = G^r_{xx} G^r_{x_2x_1} \quad , \quad (37)$$

we have

$$\begin{aligned} (G^r M G^r)_{xx} &= \sum_{x_1 x_2} G^r_{xx_1} M_{x_1 x_2} G^r_{x_2 x} \\ &= G^r_{xx} \sum_{x_1 x_2} G^r_{x_2 x_1} M_{x_1 x_2} \\ &= G^r_{xx} Tr[G^r M] \end{aligned} \quad (38)$$

where M is a matrix. Eq.(36) becomes,

$$\begin{aligned} \frac{d\sigma_{12}}{dE} &= -2\pi Im[G^r_{xx} Tr(\Gamma_2 G^a \Gamma_1 G^r)] \\ &= \frac{i}{2\pi} (G^r_{xx} - G^a_{xx}) T = \frac{T}{2} \frac{d\sigma}{dE} \end{aligned} \quad (39)$$

where $T = Tr(\Gamma_2 G^a \Gamma_1 G^r)/(4\pi^2)$ is the transmission coefficient [25] which is a real quantity; $d\sigma/dE$ is the total local DOS.

Taking energy derivative of Eq.(36), we obtain

$$\begin{aligned} \frac{d^2\sigma_{12}}{dE^2} &= 2\pi Im[(G^r G^r \Gamma_2 G^a \Gamma_1 G^r)_{xx} \\ &\quad + (G^r \Gamma_2 G^a G^a \Gamma_1 G^r)_{xx} \\ &\quad + (G^r \Gamma_2 G^a \Gamma_1 G^r G^r)_{xx}] \quad . \end{aligned} \quad (40)$$

The first term of (40) can be simplified using Eq.(38) as follows,

$$\begin{aligned} (G^r G^r \Gamma_2 G^a \Gamma_1 G^r)_{xx} &= G_{xx}^r \text{Tr}(G^r \Gamma_2 G^a \Gamma_1 G^r) \\ &= G_{xx}^r \text{Tr}(G^r) \text{Tr}(\Gamma_2 G^a \Gamma_1 G^r) = \frac{T}{4\pi^2} (G^r G^r)_{xx} . \end{aligned} \quad (41)$$

The other two terms of Eq.(40) can be simplified in a similar fashion. We thus have

$$\begin{aligned} \frac{d^2 \sigma_{12}}{dE^2} &= \frac{T}{2\pi} \text{Im}[2(G^r G^r)_{xx} + (G^r G^a)_{xx}] \\ &= -\frac{iT}{\pi} [(G^r G^r)_{xx} - (G^a G^a)_{xx}] = T \frac{d^2 \sigma}{dE^2} . \end{aligned} \quad (42)$$

In deriving the last equation we used the fact that $G^r G^a$ is a real quantity. Using (42) we find

$$\begin{aligned} \frac{d^2 \sigma_{11}}{dE^2} + \frac{d^2 \sigma_{22}}{dE^2} &= \frac{d^2 \sigma}{dE^2} - \frac{d^2 \sigma_{12}}{dE^2} - \frac{d^2 \sigma_{21}}{dE^2} \\ &= (1 - 2T) \frac{d^2 \sigma}{dE^2} . \end{aligned} \quad (43)$$

Now we consider a system with a DC current passing through. Due to polarization we again divide the system into two regions Ω_I and Ω_{II} . In the semiclassical treatment where the tunneling is neglected, the partial DOS $d^2 \sigma_{22}/dE^2 = 0$ in region I, and similarly $d^2 \sigma_{11}/dE^2 = 0$ in region II. These relations and Eqs.(42) and (43) lead to

$$\frac{d^2 \sigma_{k\alpha\beta}}{dE^2} = \frac{d^2 \sigma}{dE^2} \{T + \delta_{\alpha\beta}[(1 - 2T)\delta_{\alpha k} - T]\} \quad (44)$$

where k labels the polarization region Ω_k . For two probe system, it gives

$$\frac{d^2 \sigma_{k\alpha}}{dE^2} = \frac{d^2 \sigma}{dE^2} [T + (1 - 2T)\delta_{\alpha k}] . \quad (45)$$

This expression is the semiclassical second order nonlinear LPDOS, which is in contrast to the semiclassical linear LPDOS Eq.(11) derived in Ref. [13]. The nonlinear LPDOS plays a crucial role in determining the nonlinear electrochemical capacitance, as given in Section II.

VI. APPENDIX B

In this appendix, we give an example of calculating the second order nonlinear capacitance C_{111} by directly solving Poisson equation. This can be done analytically only for very simple systems.

Consider a system which consists of three regions: two leads (region I and III) and an infinite potential barrier (region II). Since the calculation is perturbative, we have to calculate the linear characteristic potential by solving Poisson equation Eq.(29). We assume that the partial local DOS $d\sigma_1/dE$ and $d^2\sigma_1/dE^2$ are constant in region I and zero otherwise [5]. Similarly $d\sigma_2/dE$ and $d^2\sigma_2/dE^2$ are constant in region III and zero otherwise. The solution of the Poisson equation Eq.(29) is

$$\begin{aligned} \text{region I : } u_1 &= 1 - A_1 \exp\left(\frac{x}{\lambda_1}\right) \\ \text{region II : } u_1 &= a_1 x + b_1 \\ \text{region III : } u_1 &= A_2 \exp\left(-\frac{x}{\lambda_2}\right) \end{aligned} \quad (46)$$

where A_1 , A_2 , a_1 , and b_1 are constants to be determined. In Eq.(46), we have defined the screening length $\lambda_\alpha^{-2} = 4\pi d\sigma_\alpha/dE$ and the boundary conditions [5] that $u_1 \rightarrow 1$ as $x \rightarrow -\infty$ and $u_1 \rightarrow 0$ as $x \rightarrow \infty$ have been used. Using the boundary condition that u_1 and du_1/dx be continuous at $x = a/2$ and $-a/2$, it is straightforward to find

$$\begin{aligned} a_1 &= \frac{1}{a + \lambda_1 + \lambda_2}, \quad b_1 = \frac{a_1}{2}(a + 2\lambda_2) \\ A_1 &= a_1 \lambda_1 \exp\left(\frac{a}{2\lambda_1}\right), \quad A_2 = a_1 \lambda_2 \exp\left(\frac{a}{2\lambda_2}\right) \end{aligned} \quad (47)$$

The linear electrochemical capacitance can be obtained immediately,

$$\begin{aligned} C_{11} &\equiv \int_{\Omega_I} \frac{\partial \rho(x)}{\partial V_1} dx \\ &= \frac{-1}{4\pi} \int_{\Omega_I} \nabla^2 u_1 dx \\ &= \frac{-1}{4\pi} \nabla u_1|_{-a/2} \cdot A \\ &= \frac{A}{4\pi} \frac{1}{a + \lambda_1 + \lambda_2} \end{aligned} \quad (48)$$

where A is the cross-section area of the metallic wire. Using the global DOS $dN_\alpha/dE = \text{Volume } d\sigma_\alpha/dE = \lambda_\alpha A d\sigma_\alpha/dE = A/4\pi\lambda_\alpha$, we arrive at the result first obtained by Büttiker [5],

$$\frac{1}{C_{11}} = \frac{4\pi a}{A} + \frac{1}{dN_1/dE} + \frac{1}{dN_2/dE} \quad (49)$$

With the solution of u_1 , the Eq.(30) becomes

$$\begin{aligned} \text{region I :} \quad & -\nabla^2 u_{11} + \frac{1}{\lambda_1^2} u_{11} = \frac{1}{\lambda_1^2} A_1^2 \exp\left(\frac{2x}{\lambda_1}\right) \\ \text{region II :} \quad & \nabla^2 u_{11} = 0 \\ \text{region III :} \quad & -\nabla^2 u_{11} + \frac{1}{\lambda_2^2} u_{11} = \frac{1}{\lambda_2^2} A_2^2 \exp\left(\frac{2x}{\lambda_2}\right) \end{aligned} \quad (50)$$

where we have introduced another screening length $\bar{\lambda}_\alpha^{-2} = 4\pi d^2\sigma_\alpha/dE^2$ corresponding to LPDOS $d^2\sigma_\alpha/dE^2$ and A_1 and A_2 are known from the calculation of u_1 . The solution of Eq.(50) is

$$\begin{aligned} \text{region I :} \quad & u_{11} = -\frac{\lambda_1^2}{3\lambda_1^2} A_1^2 \exp\left(\frac{2x}{\lambda_1}\right) + B_1 \exp\left(\frac{x}{\lambda_1}\right) \\ \text{region II :} \quad & u_{11} = a_2 x + b_2 \\ \text{region III :} \quad & u_{11} = -\frac{\lambda_2^2}{3\lambda_2^2} A_2^2 \exp\left(\frac{2x}{\lambda_2}\right) + B_2 \exp\left(\frac{x}{\lambda_2}\right) \end{aligned} \quad (51)$$

After matching boundary conditions at $x = a/2, -a/2$, we obtain

$$B_1 \exp\left(\frac{-a}{2\lambda_1}\right) = \frac{\lambda_1}{(a + \lambda_1 + \lambda_2)^3} \left[\frac{2\lambda_1^3 a + \lambda_1^4 + 2\lambda_1^3 \lambda_2}{3\lambda_1^2} + \frac{\lambda_2^4}{3\lambda_2^2} \right] \quad (52)$$

The second order nonlinear electrochemical capacitance C_{111} is

$$\begin{aligned} C_{111} &\equiv \frac{1}{2} \int_{\Omega_I} \frac{\partial^2 \rho(x)}{\partial V_1^2} dx \\ &= \frac{-1}{4\pi} \nabla u_{11}|_{-a/2} \cdot A \\ &= \frac{\lambda_1}{6\pi\lambda_1^2} A_1^2 \exp\left(-\frac{a}{\lambda_1}\right) - \frac{B_1}{4\pi\lambda_1} \exp\left(-\frac{a}{2\lambda_1}\right) \\ &= \frac{A}{4\pi} \frac{1}{(a + \lambda_1 + \lambda_2)^3} \left[\frac{\lambda_1^4}{3\lambda_1^2} - \frac{\lambda_2^4}{3\lambda_2^2} \right] \end{aligned} \quad (53)$$

From the definition of the screening length, we have

$$\frac{\lambda_\alpha}{A} = \frac{1}{4\pi A \lambda_\alpha d\sigma_\alpha/dE} = \frac{1}{dN_\alpha/dE} \quad (54)$$

where we have used the fact that there is charge polarization only in the region $A\lambda_\alpha$. Similarly, we obtain

$$\frac{\bar{\lambda}_\alpha}{A} = \frac{1}{d^2 N_\alpha/dE^2} \quad (55)$$

With the help of Eqs.(54), (55), and (49), we finally have

$$C_{111} = \frac{C_{11}^3}{3} \left[\frac{d^2 N_1/dE^2}{(dN_1/dE)^3} - \frac{d^2 N_2/dE^2}{(dN_2/dE)^3} \right] \quad (56)$$

which agrees with Eq.(23).

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$$C_o\left(\frac{dU_1}{dV} - \frac{dU_2}{dV}\right) = C_\mu + V\frac{dC_\mu}{dV}.$$
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FIGURE CAPTIONS

Fig. (1) The energy band configuration for a model barrier. Near the barrier the band bottom is different from that away the barrier. The inset is an ideal experimental setup of which the energy band is schematically shown in the figure.

Fig. (2) The linear electrochemical capacitance as a function of barrier width W for a square barrier with the barrier height $H_0 = 0.8$. The solid line is the full quantum numerical calculation C , the dashed line and dotted line are from the quantum result C_q and the semi-classical result C_s in the discrete potential approximation, respectively. The dot-dashed line is the classical result $C \sim 1/W$. The inset: the corresponding partial density of states versus the barrier width W . The solid line is $dN_{11}(\Omega_{II})/dE$ and the dotted line is $dN_{12}(\Omega_{II})/dE$.

Fig. (3) (a). The linear electrochemical capacitance as a function of barrier width W for the asymmetric barrier (see inset). The system parameters are $W_1 = W_2$, $H_1 = 0.2$, $H_2 = 1.0$. (b). The second order nonlinear electrochemical capacitance versus W . In Fig.(3a) and (3b), the solid, dashed, and dotted lines correspond to C , C_q , and C_s , respectively. In Fig.(3b), we have multiplied C_q and C_s by a factor of 5. The inset

of Fig.(3b): the corresponding partial DOS D_I (solid line) and $\bar{D}_I$ (dotted line) as a function of W . For illustrating purpose, we have divided $\bar{D}_I$ by a factor of 30.

Fig. (4) The linear (solid line) and nonlinear (dashed line) charge distribution for the asymmetric barrier, where $W = 20$, $H_1 = 0.2$, and $H_2 = 1.0$. The dotted line shows the shape of asymmetric barrier.

Fig.1

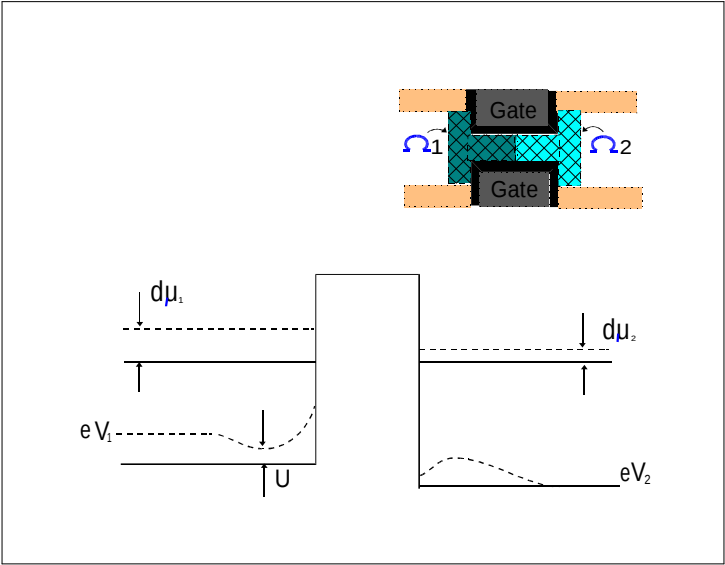


fig.2

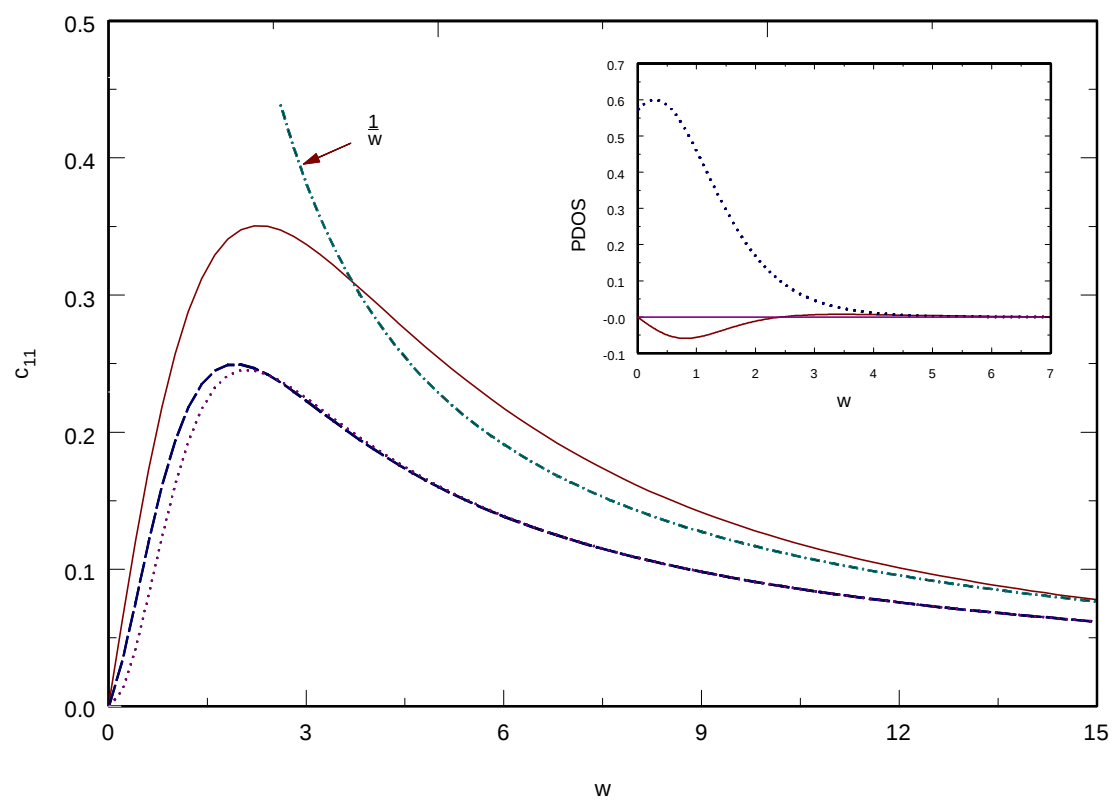


Fig.3a

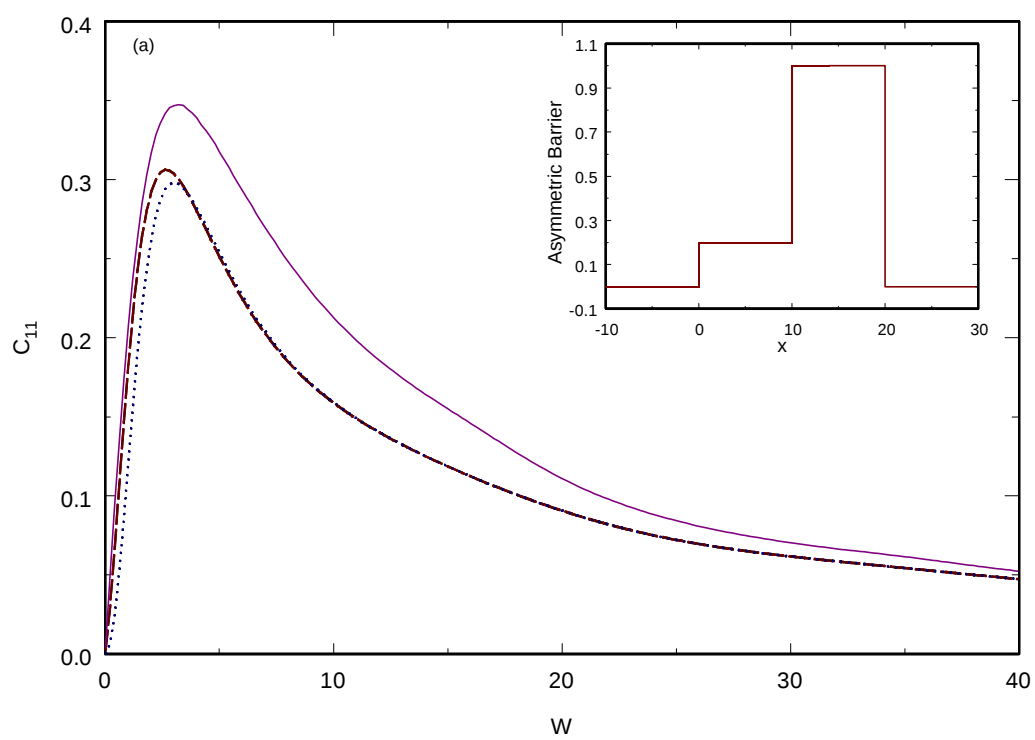


Fig.3b

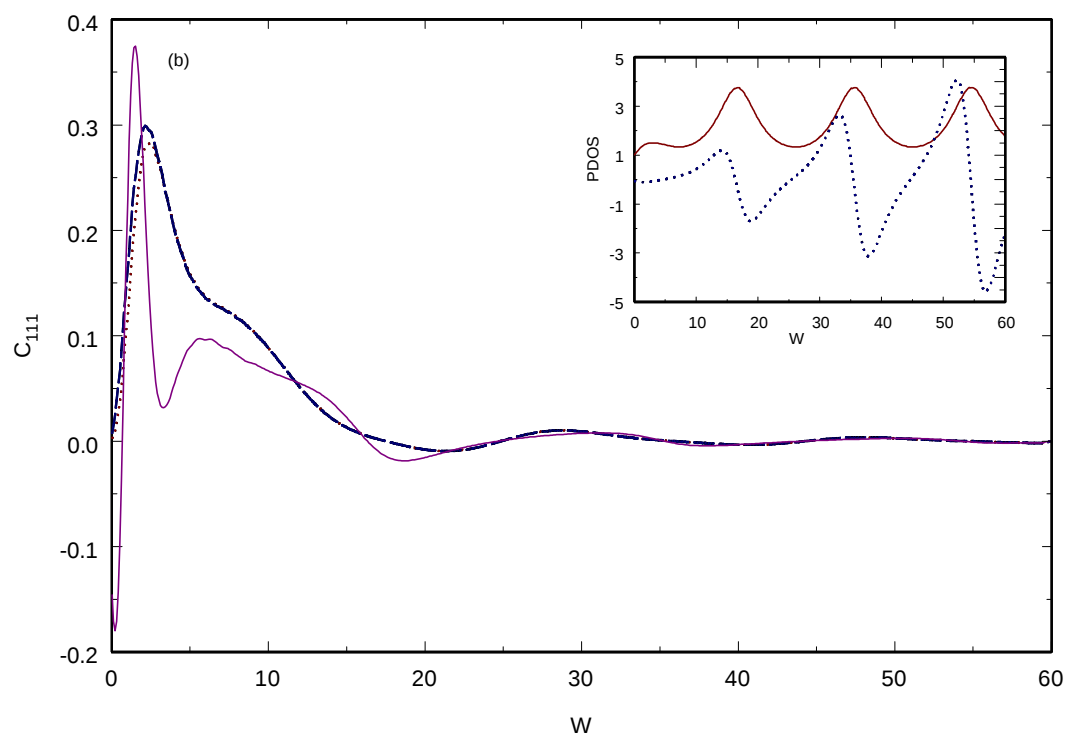


Fig.6

